

FEA on the Conceptual Design of the FPIX substrate for the CMS upgrade

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Material Budget

CMS Forward Pixel Blade Radiation Length Estimate

2 Oct 2004

Assumes: Blade mass spread out evenly over area of a 3e substrate face
Normal tracks (10deg cambar not accounted for)

NEL Calc Assumes Mass Averaged over an Effective Area of 41.78 cm²

			Volume Fract.	Length (mm)	Width (mm)	Thickness (mm)	SubAssembly Volume (mm ³)	Qty	Total Volume (mm ³)	Density (g/mm ³)	Mass (g)	Matl Rad Leng (g/cm ²)	NEL	Percent of Total NEL
Sensors												4.9	0.50	12.0
1x2	CNTEKFFE.0001		1.00	18.49	18.39	0.270	51.9	1	51.9	0.00232	0.121	22.92	0.01	0.3
1x2	CNTEKFFE.0002		1.00	42.79	18.39	0.270	120.1	1	120.1	0.00232	0.280	22.92	0.03	0.7
1x2	CNTEKFFE.0003		1.00	26.59	18.49	0.270	132.9	2	265.8	0.00232	0.619	22.92	0.07	1.6
1x2	CNTEKFFE.0004		1.00	34.69	18.49	0.270	173.2	2	346.5	0.00232	0.807	22.92	0.09	1.1
1x2	CNTEKFFE.0005		1.00	42.79	18.49	0.270	213.7	1	213.7	0.00232	0.498	22.92	0.05	1.3
FEI-46 chip	CNTEKFFE.0006		1.00	9.94	9.92	0.190	18.1	45	809.0	0.00232	1.894	22.92	0.17	4.1
Bump Bonds		(63/37 Tin/Lead)	1.00	9.92	9.92	0.025	9.0	187200	2.9	0.00880	0.026	7.72	0.01	0.2
Chothermal290 (VHDI-to-chip)	See doorb #921	Acrylic	1.00	9.94	9.92	0.025	2.0	45	89.5	0.00140	0.098	46.00	0.01	0.1
		BN powder	0.20	9.94	9.92	0.125	2.0	45	89.5	0.00560	0.313	42.39	0.03	0.4
		Silicone	0.80	9.94	9.92	0.125	8.0	45	357.9	0.00130	0.465	25.13	0.04	1.0
		Polyimide	1.00	9.94	9.92	0.025	2.0	45	89.5	0.00140	0.125	28.39	0.01	0.2
VHDIe												8.7	0.93	22.4
Substrates	CNTEKFFE.0008 & 0009	1 x 2	1.00	21.36	15.05	0.390	96.4	1	96.4	0.00232	0.225	22.92	0.01	0.6
	CNTEKFFE.0010 & 0011	1 x 5	1.00	45.65	15.05	0.390	204.1	1	204.1	0.00232	0.480	22.92	0.05	1.3
	CNTEKFFE.0012	2 x 3	1.00	29.45	27.77	0.390	245.4	2	490.9	0.00232	1.143	22.92	0.13	3.0
	CNTEKFFE.0013	2 x 4	1.00	38.55	27.77	0.390	321.2	2	642.4	0.00232	1.497	22.92	0.16	3.9
	CNTEKFFE.0014	2 x 5	1.00	45.65	27.77	0.390	389.2	1	389.2	0.00232	0.896	22.92	0.09	1.3
IM 9881 tape (VHDI to substrate)	See doorb #921	Acrylic assumed	0.80	Tot Area =	4953.26	0.050	242.1	1	242.1	0.00118	0.285	46.00	0.01	0.4
		Ceramic (BN assumed)	0.20	Tot Area =	4953.26	0.050	60.5	1	60.5	0.00560	0.332	42.39	0.01	0.3
VHDIe	V.C. small 10/3/04	Kapton	1.00	Tot Area =	4953.26	0.090	544.9	1	544.9	0.00140	0.763	28.39	0.05	1.1
		Copper	0.60	Tot Area =	4953.26	0.040	145.3	1	145.3	0.00920	1.351	12.96	0.25	5.9
Capacitors		(RuTiO5 assumed)	1.00	1.00	0.50	0.250	0.1	135	13.9	0.00498	0.103	11.31	0.02	0.5
Resistors		(Alumina assumed)	1.00	Volume =	0.000	0.000	0.0	0	0.0	0.00225	0.000	27.45	0.01	0.1
Solder		(63/37 Tin/Lead)	1.00	0.20	0.000	0.000	0.0	270	5.4	0.00880	0.048	7.72	0.01	0.2
Chothermal290 (VHDI-to-plaquette)	See doorb #921	Acrylic assumed	1.00	Tot Area =	4953.26	0.025	151.3	1	151.3	0.00110	0.166	46.00	0.01	0.2
		BN powder	0.20	Tot Area =	4953.26	0.125	151.3	1	151.3	0.00560	0.820	42.39	0.03	0.7
		Silicone	0.80	Tot Area =	4953.26	0.125	605.3	1	605.3	0.00130	0.787	25.13	0.07	1.8
		Polyimide	1.00	Tot Area =	4953.26	0.025	151.3	1	151.3	0.00140	0.212	28.39	0.01	0.3
HDIs												12.5	0.80	19.2
Substrates	CNTEKFFE.0007	(3e)	1.00	Area =	4279.00	0.100	2179.2	2	4346.4	0.00185	8.032	61.19	0.29	6.9
MDI	V.C. small 10/3/04	Kapton	1.00	Area =	4279.00	0.100	427.9	2	855.8	0.00140	1.198	28.39	0.07	1.8
		Internal flat adhesive	1.00	Area =	4279.00	0.050	213.9	2	427.9	0.00125	0.525	46.00	0.03	0.8
		Copper	0.20	Area =	4279.00	0.057	67.5	2	134.9	0.00920	1.255	12.96	0.23	5.5
Capacitors		(RuTiO5 assumed)	1.00	0.75	0.50	0.640	0.2	9	1.9	0.00498	0.052	11.31	0.01	0.1
Resistors		(Alumina, NTD added as 2 extra)	1.00	0.75	0.50	0.640	0.2	9	2.2	0.00225	0.007	27.45	0.01	0.1
Solder		(63/37 Tin/Lead)	1.00	Volume =	0.000	0.000	0.5	17	8.5	0.00880	0.075	7.72	0.01	0.2
TSM Chip		Silicon	1.00	4.43	3.20	0.600	8.4	2	1.3	0.00232	0.003	22.92	0.01	0.1
IM 9881 tape (MDI to substrate)	See doorb #921	Acrylic assumed	0.80	Area =	4279.00	0.050	171.1	2	342.2	0.00110	0.376	46.00	0.01	0.3
		Ceramic (BN assumed)	0.20	Area =	4279.00	0.050	42.8	2	85.6	0.00560	0.299	42.39	0.01	0.4
Blas / Ground Wires	CNTEKFFE.0112	Copper	1.00	Area =	0.98	98.000	6.0	6	36.2	0.00920	0.327	12.96	0.06	1.5
		Kapton	1.00	0.22	98.000	19.1	6	109.7	0.00140	0.152	28.39	0.01	0.2	
		Solder (63/37 Tin/Lead)	1.00	Volume =	1.000	1.0	12	12	12.0	0.00880	0.104	7.72	0.01	0.1
		Epoxy	1.00	Volume =	16.000	16.0	2	20.0	0.00110	0.022	46.00	0.01	0.1	
		IM Solder (12In 48Sn)	1.00	Volume =	3.000	3.0	2	6.0	0.00720	0.044	8.93	0.01	0.2	
Support Hardware												20.9	1.92	46.3
Panel + Channel Screws		(Ti, M6.6)	1.00	Volume =	13.624	13.6	9	122.6	0.00454	0.517	16.17	0.08	1.9	
Cooling Channel	CNTEKFFP.0115 & 0116	(Al, includes 1 jumper)	1.00	Volume =	2261.9	2261.9	1	2261.9	0.00270	6.091	24.01	0.86	21.4	
Outer Ring	CNTEKFFP.0120-A	(Al, model vol. / 12)	1.00	Volume =	1774	1773.9	1	1773.9	0.00270	4.790	24.01	0.47	11.2	
Inner Ring	CNTEKFFP.0124	(Al, model vol. / 12)	1.00	Volume =	796	796.1	1	796.1	0.00270	2.150	24.01	0.21	5.1	
Coolant		(CEFl4 -- volume from V.P.)	1.00	Volume =	16130.0	16130.0	0.1647	2686.3	0.00179	4.628	34.92	0.21	7.3	

DOES NOT INCLUDE:

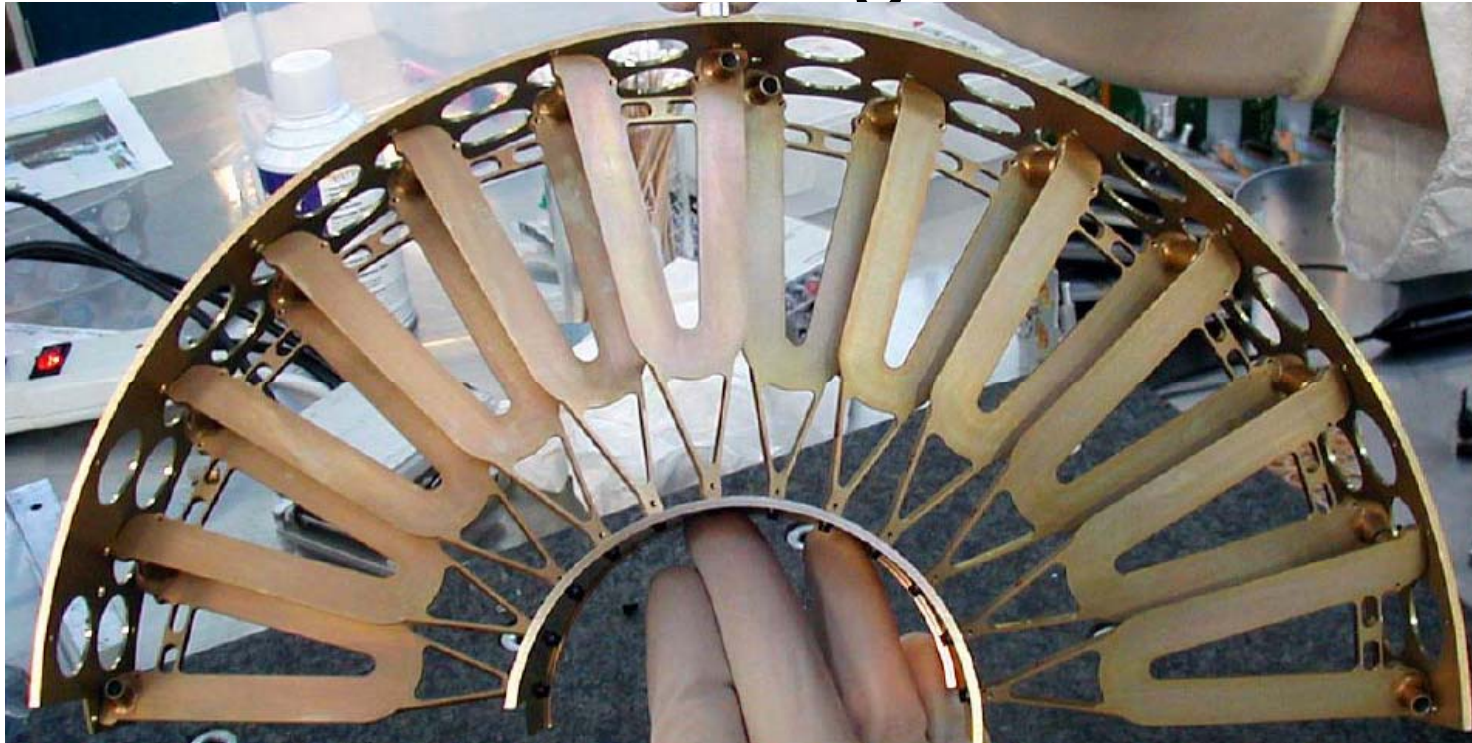
Adapter Board

Cable plumbing hardware

Survey Balls

Total = 4.16 %EL
Total = 47 grams

The Al cooling channel



They are the most complicated component of the Disk. They are made out of 2 blocks of Al aluminum brazed together. It took 5 prototyping submissions, with Bodycote, over 5 years to develop a reliable process.

1 st Brazing U. Miss.	Dec 2000 - Sep 03	Data Base #	xxxxxxx
2 nd Brazing FNAL	Nov 02 - May 03	Data Base #	xxxxxxx
3 rd Brazing FNAL	Mar 03 - Jun 03	Data Base #	xxxxxxx
4 th Brazing FNAL	Jun 03 - Apr 04	Data Base #	xxxxxxx
5 th Brazing FNAL	Feb 05 - Dec 05	Data Base #	xxxxxxx

Prototypes from last subm. have been used to assemble the first ½-Disk

For each of the $\pm z$ sides 3 types of channels are needed!

Material Candidates

	Density g/cc	Modulus, E_ab Gpa	Modulus, E_c Gpa	Strength Mpa	Thermal K_ab W/m-K	Thermal K_c W/m-K	cte_ab ppm/K	cte_c ppm/K	Rad L, X0 cm
Porous Materials									
fuzzy C, 5% pr	0.11	-	-		-	55	-	1.0	406.7
carbon foam, low density	0.25	0.9			15	20	3.5		170.8
SiC foam, 8% packing ratio	0.26	2.8	2.8		11	11	2.2	2.2	166.1
RVC foam (vitreous C)	0.30	0.1	0.1	0.3	0.5	0.5	2.2	2.2	142.3
carbon foam, medium density	0.35	3.0		-1.6	20	25	3.5		122.0
carbon foam, high density	0.45	5.0		-3.5	25	40	3.5		94.9
poco-foam, 25% pr	0.55	20.7	20.7	-2.07	45	135	2.5	2.5	77.6
rohacell	0.03	0.0	0.0	1	0.0	0.0	37.0	37.0	1497.7
Solid Non-metallic Materials									
pyrolitic graphite, PGS	1				600	600.0	0.9	32.0	42.7
peek	1.32	3.6	3.6	92.9	0.2	0.2	46.8	46.8	35.0
CoolPoly E5101 (PPS)	1.70	13.0	13.0	45.0	20	20	15.0	15.0	26.5
CFRP (M46J-epoxy)	1.61	18.1	7.3		56	0.7	0.0	30.2	26.5
glassy C	1.65	20.0	20.0		5	5	3.0	3.0	25.9
CFRP (K13C2U-epoxy)	1.75	483.0	6.2		320	0.5	-1.0	26.0	24.4
CFRP (K139-EX1515)	1.76	154.0	6.4		63	0.4	-0.8	30.4	24.3
Poco graphite ACF-10Q	1.77	11.0	11.0	69.0	60	60	7.6	7.6	24.1
C-C composite (carbon fiber/carbon matrix)	1.80	152.0	4.8		225	150	2.0	2.0	23.7
SiC	3.21	466.0	466.0	-3900	40	40	3.3	3.3	8.1
G10 (glass fiber/epoxy)	1.8	17.2		262.0	0.3	0.3	11.9	11.9	19.4
pyrolitic graphite, TPG	2.26	1050.0	36.0		1700	10	-1.0	25.0	18.9
Alumina Silicate	2.80			17.5	1.2	1.2	2.9	2.9	14.2
Vespel SP1 Polyimide	1.43	2.4	2.4	87.3	0.3	0.3	54.0	54.0	31.9
CVD Diamond	3.51	1000.0	1000.0	400.0	2000	2000	1.0	1.0	12.0
DLC (diamond-like carbon) coating									
Solid Metallic									
Be	1.85	290.0	290.0	276	145	145	11.6	11.6	35.4
AlBeMet	2.10	200.0	200.0	192	210	210	13.9	13.9	16.1
BeO	2.90	345.0	345.0	138000	330	330	7.6	7.6	13.3
Aluminum Nitride (AlN)	3.26	331.0	331.0	-2100	165	165	4.5	4.5	10.3
silicon	2.33	110.3	110.3	-120	120	120	2.6	2.6	9.4

Items Selected for the Conceptual Design

- Material selected for Substrate
 - TPG laminated with carbon-fiber reinforced plastic
 - Low mass ($X_0 = 18.9$ cm)
 - Radiation hard
 - Dimensionally stable
 - Very high thermal conductivity
~ 1600 W/mK at room temperature
- Cooling selected for Substrate
 - High-pressure CO₂ with small tubing
 - Low mass
 - Radiation hard
 - High thermal performance

>> small cooling tube will be used.

The major task is thus to design the cooling layout and how to bond the cooling tubing to the TPG substrate properly.

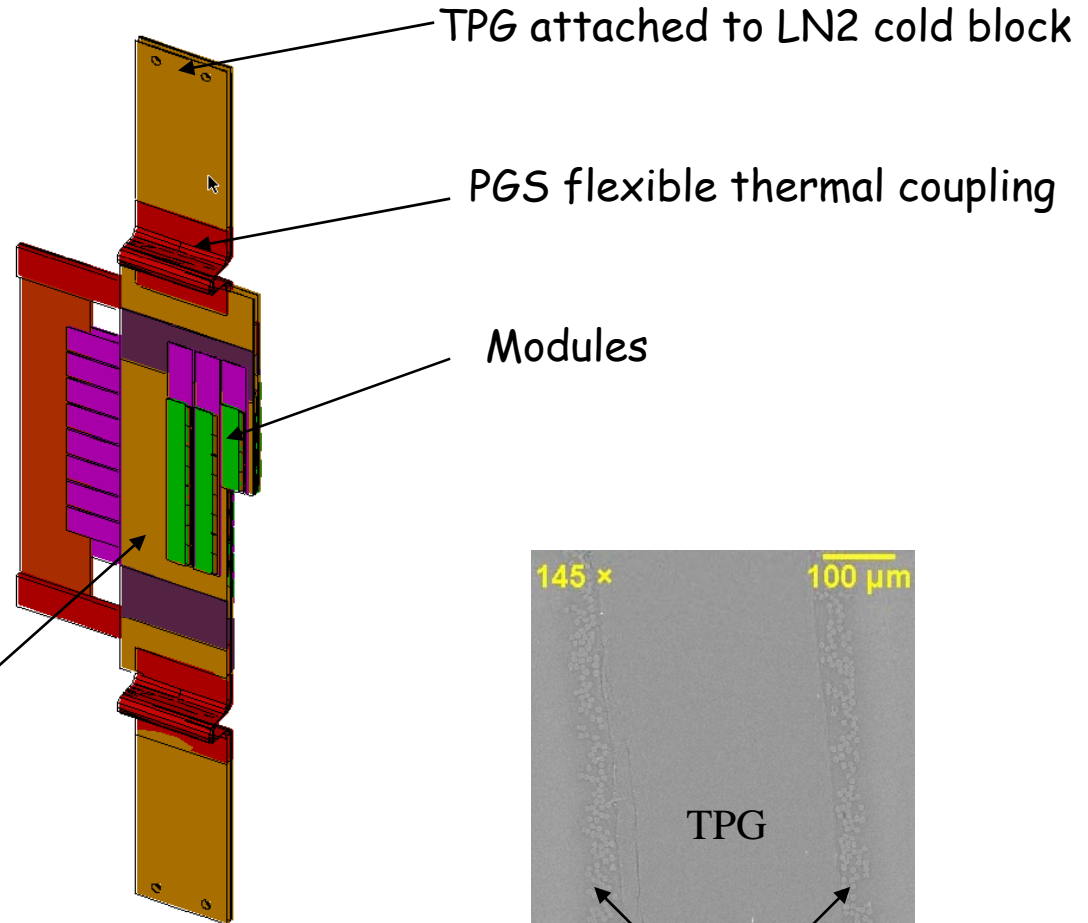
Thermal Pyrolytic Graphite (TPG)

- A unique form of pyrolytic graphite
- Made by the decomposition of a hydrocarbon gas within vacuum furnace
- High thermal conductivity (in-plane $k =$ up to 1700 W/m-K, out-of-plane $k =$ 10W/m-K at room temperature)
- Low CTE (in-plane = -1 ppm/C, out-of-plane = 25 ppm/C)
- Low density = 2.26 g/cc
- $X0 = 18.9$ cm ($X0*k = 321$ W/K vs 51 W/K of Be)
- Friable, needs encapsulation; carbon fiber composite is chosen for needed rigidity within material budget constraint.
- Extensive studies performed by BTeV from 2002-2005. Also used by ATLAS (strips) and LHCb.
- Vendors:
 - Momentive Performance Materials (<http://advceramics.com/>)
Quote: TPG0044
TPG .38MM THKx90mmx150mm LG
.38MM +/- .03mm
20-50pc's 203.50ea.
 - MiNTEQ (<http://pyrographite.com/>)

TPG Experience at FermiLab

TPG was firstly proposed to use for BTeV pixel detector in 2003.

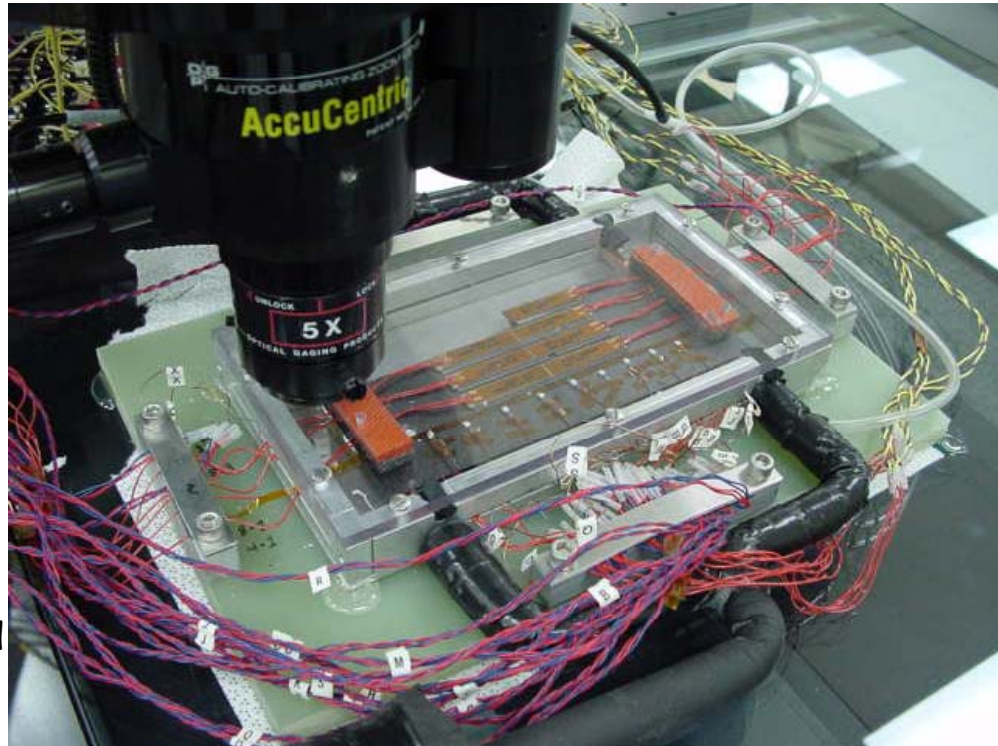
TPG encapsulated with one ply of CFRP for the facing



TPG Experience at FermiLab ...continued (1)

The BTeV prototype was made and thermal cyclic tests with heaters and cooling on and off were conducted. Results were satisfactory, no alarming problem was found.

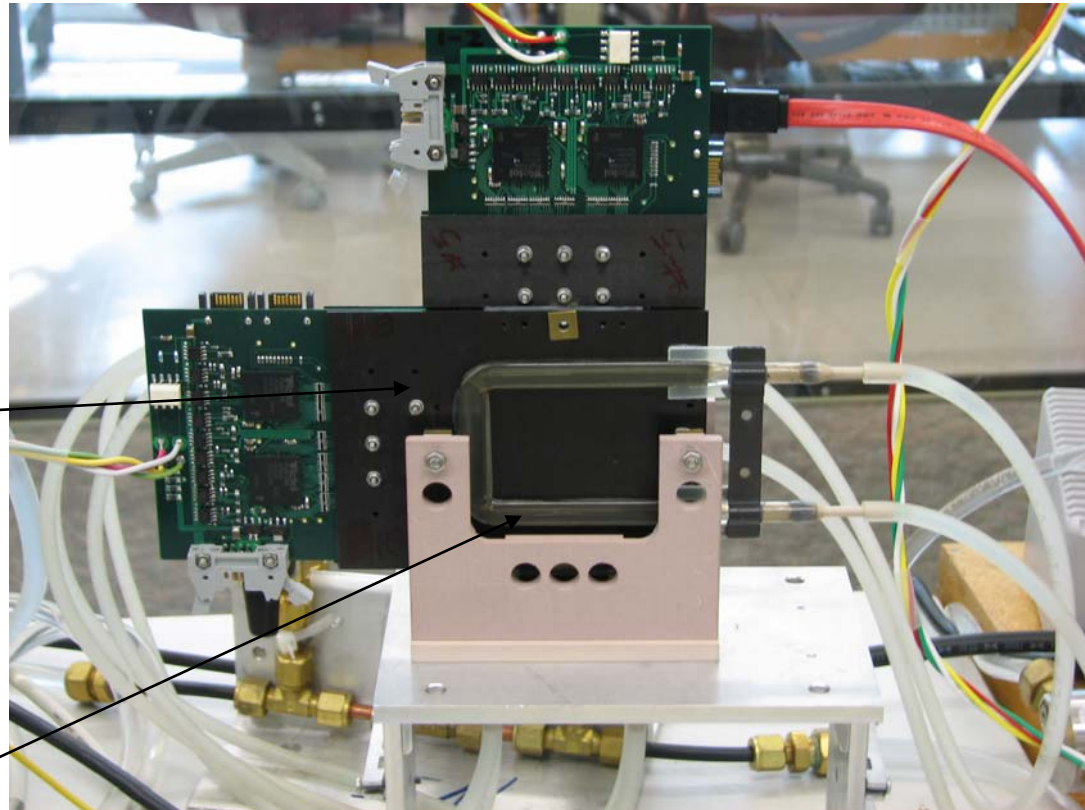
- Test was conducted within a dry box with small amount of nitrogen flowing
- Kapton heaters on dummy silicon were used to simulate module heat load
- Cooling contacts were provided at ends
- An optical camera was used to observe the target displacements
- RTDs were glued on substrate to record thermal data
- Pin & hole engagement at large end
- Pin & slot engagement at small end



TPG Experience at FermiLab - continued (2)

It was successfully used for MTest Pixel Detector this year (2008)

TPG encapsulated with two plies of CFRP for the facing



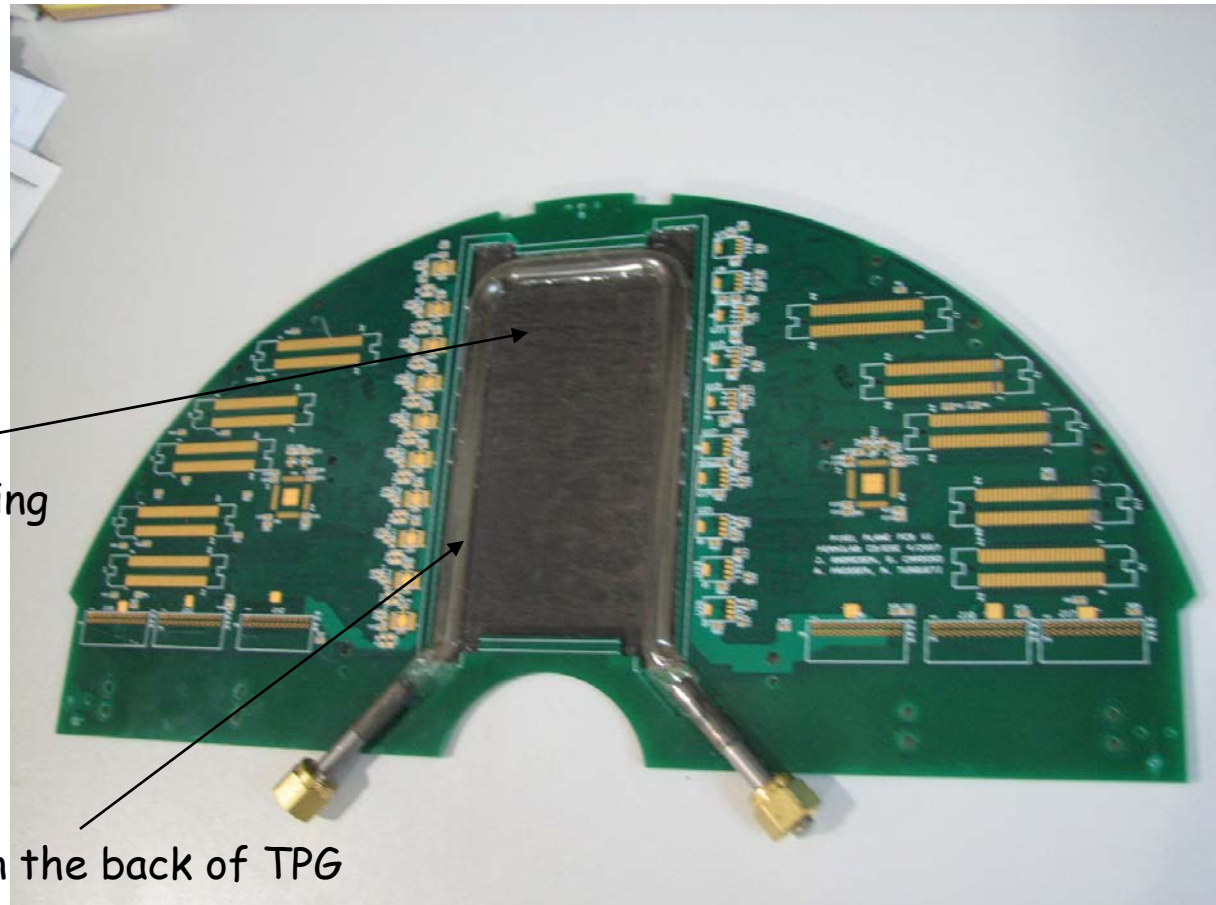
PEEK Cooling tube glued on the back of TPG

TPG Experience at FermiLab - continued (3)

It is planned to use
for the PHENIX pixel
detector as well.

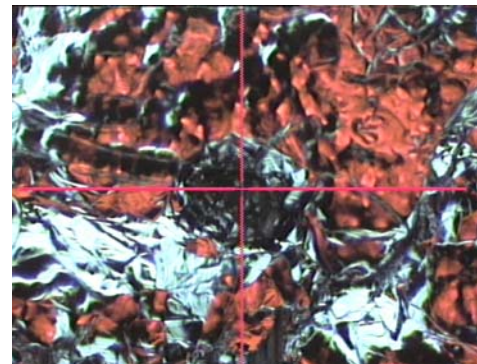
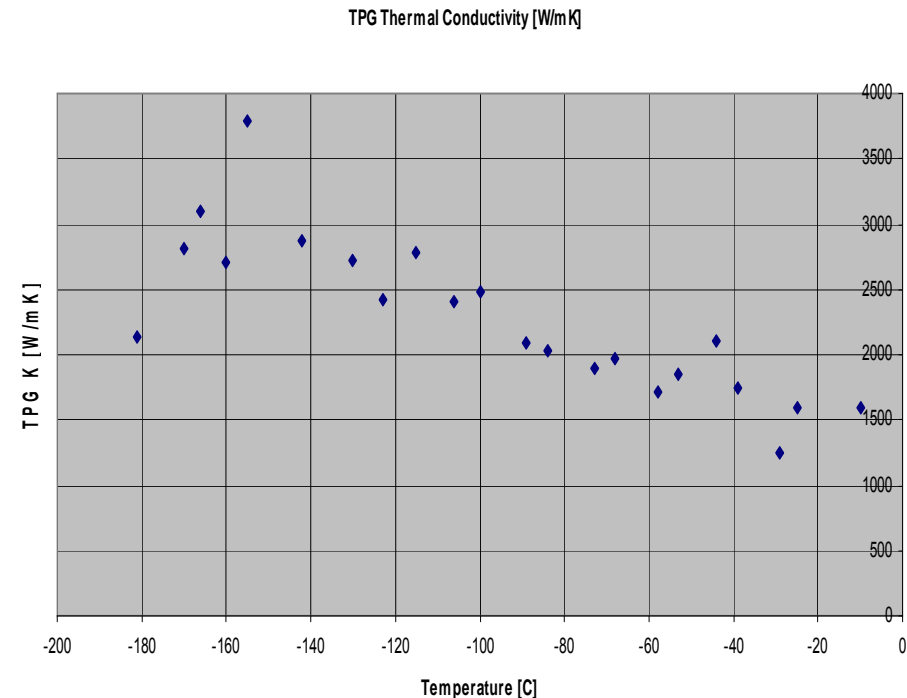
TPG encapsulated with
two plies of CFRP for the facing

PEEK Cooling tube glued on the back of TPG



TPG Experience at FermiLab - continued (4)

- No alarming problems were found.
- Perforated holes drilling on TPG was needed before encapsulation. It would improve the rigidity of the substrate.
- Tensile pulling test on encapsulated TPG samples were done, and the improved strength was verified.
- Thermal conductivity measurement of TPG were checked and its high thermal K characteristic at low temperatures was verified.
- Plasma cleaning on the CFRP encapsulated TPG was checked, the thermal performance could be slightly improved as a thin layer of the impregnated epoxy was removed.
- TPG might not be very flat due to the relief of internal stress when made at the factory. It could be flattened somewhat when CFRP was added.



This perforated hole was basically filled up completely with epoxy

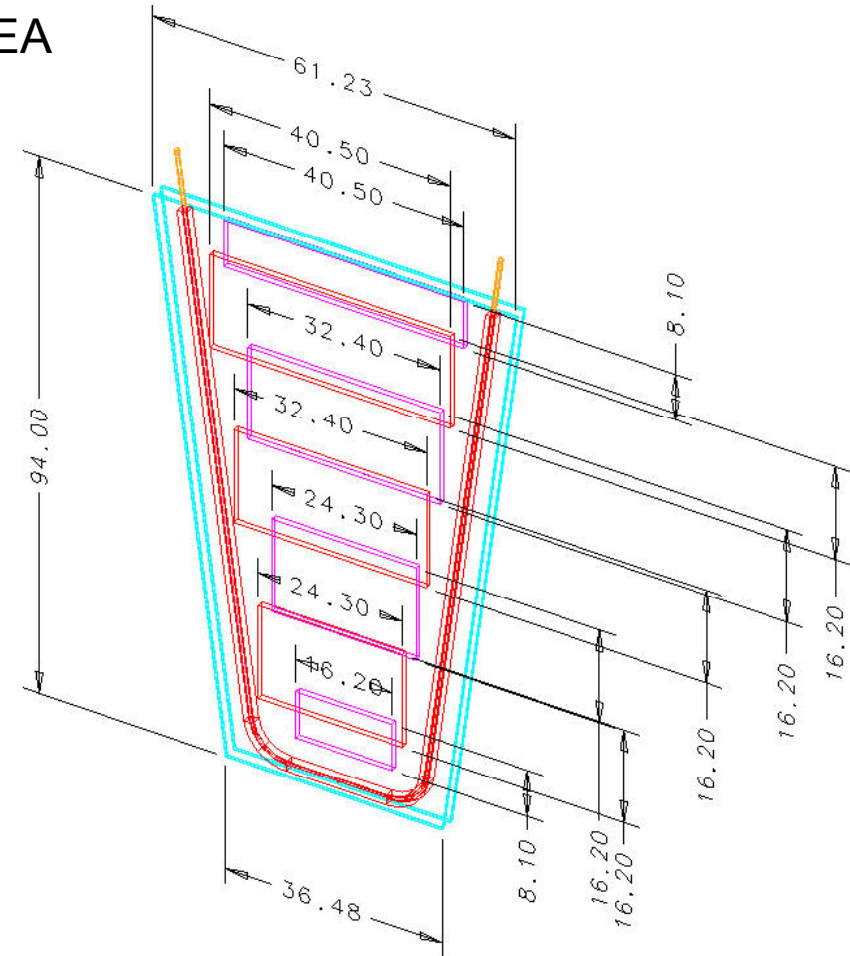
Averaged Heat Load Density used in this FEA

Sensor Dimensions			
	width, mm	height, mm	area, mm ²
1	40.5	8.1	328.05
2	40.5	16.2	656.1
3	32.4	16.2	524.88
4	32.4	16.2	524.88
5	24.3	16.2	393.66
6	24.3	16.2	393.66
7	16.2	8.1	131.22
total area =			2952.45 or 29.5245 cm ²

2X3 End Disks	Heat Load, W
ROC	962
control & driver	27
sensors	365
Total	1354

Each end disk has 24 blades, or 48 substrates,
 heat load per substrate = $1354/6/48 = 4.701$

Heat load density = $4.7W/29.5245 =$
0.159 W/cm²



The tentative basic structure – the blade, which consists of 2 substrates with cooling tubing in between.

Commercially Available ss 316L tubing

From Eagles Stainless Tube & Fabrication, Inc

SS 316L Yield strength = 2000 bars

OD, inches	t, inches	OD in mm	ID in mm	t, mm	Rad L due to 2 t	Pressure, bar due to yield	Pressure, bar with SF = 3
0.0645	0.009	1.6383	1.1811	0.2286	2.54%	558	186
0.0645	0.006	1.6383	1.3335	0.1524	1.69%	372	124
0.0645	0.004	1.6383	1.4351	0.1016	1.13%	248	83
0.0615	0.005	1.5621	1.3081	0.127	1.41%	325	108
0.0575	0.008	1.4605	1.0541	0.2032	2.26%	557	186
0.0575	0.005	1.4605	1.2065	0.127	1.41%	348	116
0.0575	0.003	1.4605	1.3081	0.0762	0.85%	209	70
0.0555	0.005	1.4097	1.1557	0.127	1.41%	360	120
0.0495	0.0085	1.2573	0.8255	0.2159	2.40%	687	229
0.0495	0.006	1.2573	0.9525	0.1524	1.69%	485	162
0.0495	0.004	1.2573	1.0541	0.1016	1.13%	323	108
0.0455	0.0065	1.1557	0.8255	0.1651	1.83%	571	190
0.0415	0.0075	1.0541	0.6731	0.1905	2.12%	723	241
0.0415	0.005	1.0541	0.8001	0.127	1.41%	482	161
0.0415	0.0035	1.0541	0.8763	0.0889	0.99%	337	112
0.0385	0.006	0.9779	0.6731	0.1524	1.69%	623	208
0.0355	0.006	0.9017	0.5969	0.1524	1.69%	676	225
0.0355	0.005	0.9017	0.6477	0.127	1.41%	563	188
0.0355	0.004	0.9017	0.6985	0.1016	1.13%	451	150
0.034	0.004	0.8636	0.6604	0.1016	1.13%	471	157
0.032	0.006	0.8128	0.508	0.1524	1.69%	750	250
0.032	0.005	0.8128	0.5588	0.127	1.41%	625	208
0.032	0.002	0.8128	0.7112	0.0508	0.56%	250	83
0.03	0.0035	0.762	0.5842	0.0889	0.99%	467	156
0.028	0.006	0.7112	0.4064	0.1524	1.69%	857	286
0.028	0.004	0.7112	0.508	0.1016	1.13%	571	190
0.028	0.0025	0.7112	0.5842	0.0635	0.71%	357	119

ss tubing used in this FEA

K Values used in this FEA

Thermal K of epoxy
(3M DP190 Gray) = 0.38 W/mK

Thermal Conductivities K of TPG, In-Plane

Temp in K	K in W/m-K
70	2920
80	3432
90	3784
100	3984
150	3624
200	2600
250	1960
273.2	1784
300	1600
350	1352
400	1168
500	904
600	744

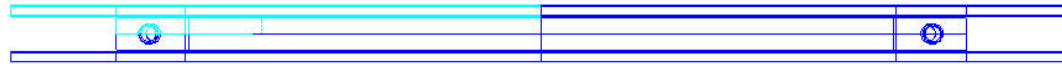
Thermal K of TPG, Out-of-Plane = 10 W/mK

- 0/90 Carbon-Fiber Facing, In-Plane = 63.3 W/mK
- 0/90 Carbon-Fiber Facing, Out-of-Plane = 0.6 W/mK
- 0 Carbon-Fiber Facing, In-Plane = 126 W/mK
- 0 Carbon-Fiber Facing, Out-of-Plane = 0.6 W/mK
- Carbon-carbon, In-Plane = 225 W/mK
- Carbon, Out-of-Plane = 150 W/mK
- Pocofoam, In-Plane = 45 W/mK
- Pocofoam, Out-of-Plane = 135 W/mK

Configurations Analyzed in this FEA

- Two cooling layouts.
 - Conf. A >> U-shape
 - Conf. B >> Lateral X2
- Two different sets of layer thickness
(same overall substrate thickness at 0.62 mm)
 - T1 >> 0.06 mm 1-ply cf + 0.50 mm TPG + 0.06 mm 1-ply cf
 - (total rad L % = 0.025% + 0.205% + 0.025% = 0.255% of X0)
 - T2 >> 0.12 mm 2-ply cf + 0.38 mm TPG + 0.12 mm 2-ply cf
 - (total rad L % = 0.049% + 0.157% + 0.049% = 0.255% of X0)

Quarter FEA Blade Model for Conf. A-T1



0.06 mm 1-ply carbon fiber facing

0.50 mm TPG

0.06 mm 1-ply carbon fiber facing

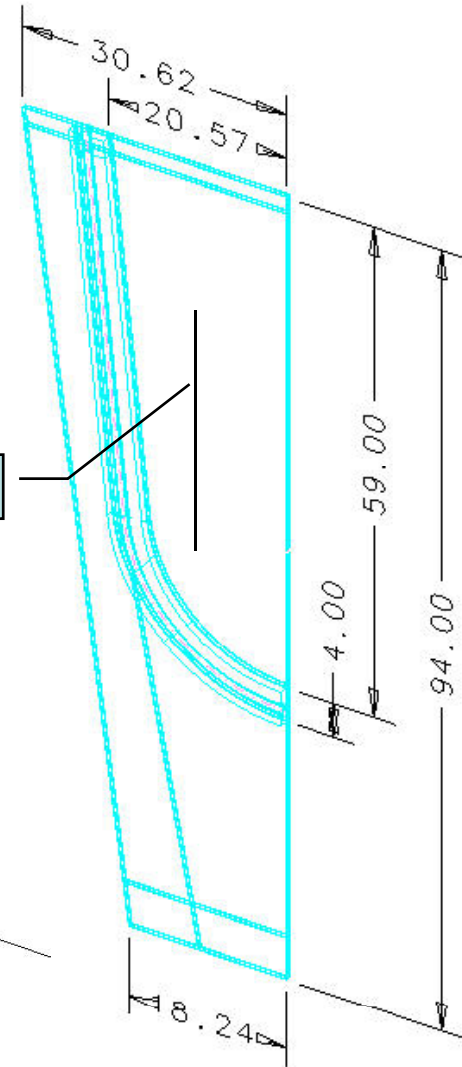
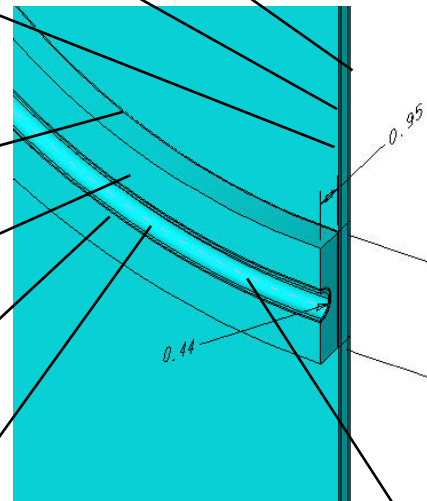
0.05 mm epoxy

0.95 mm pocof foam

0.05 mm epoxy

0.09 mm ss tubing wall

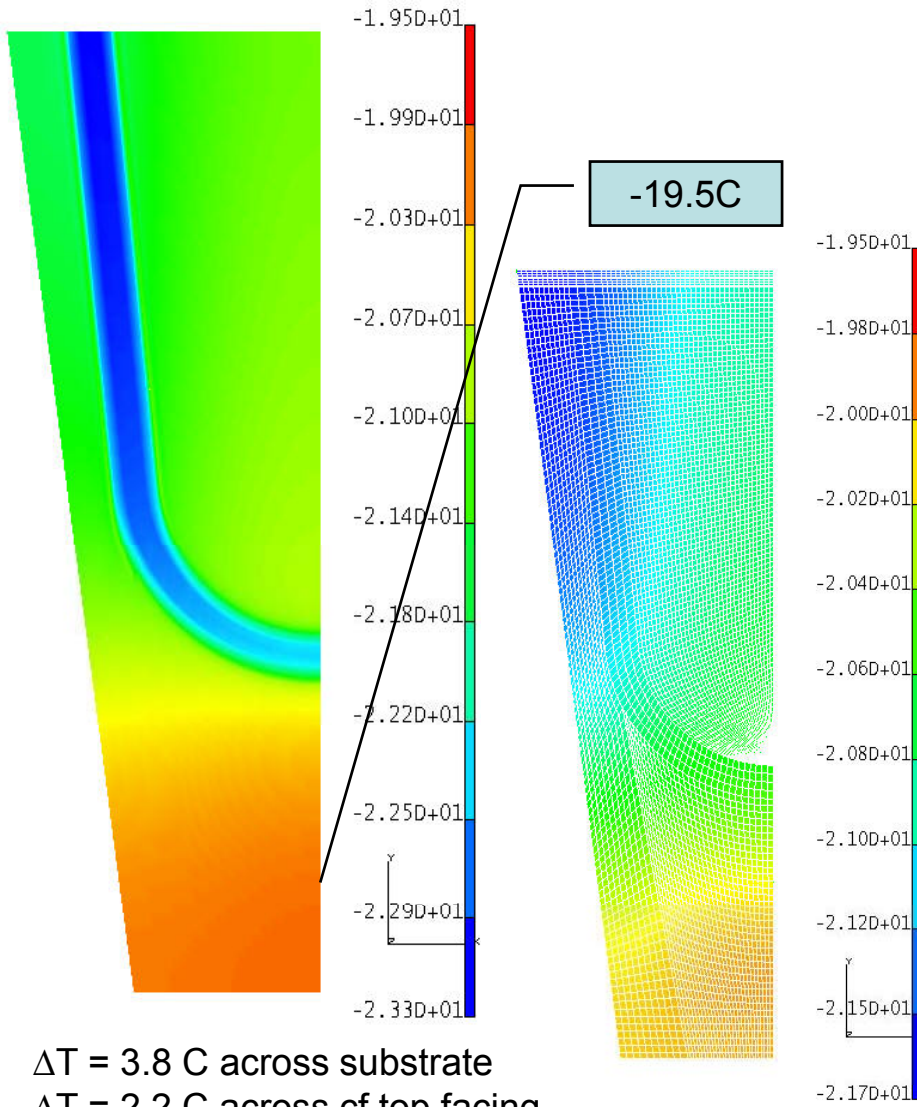
0 degree orientation for cf



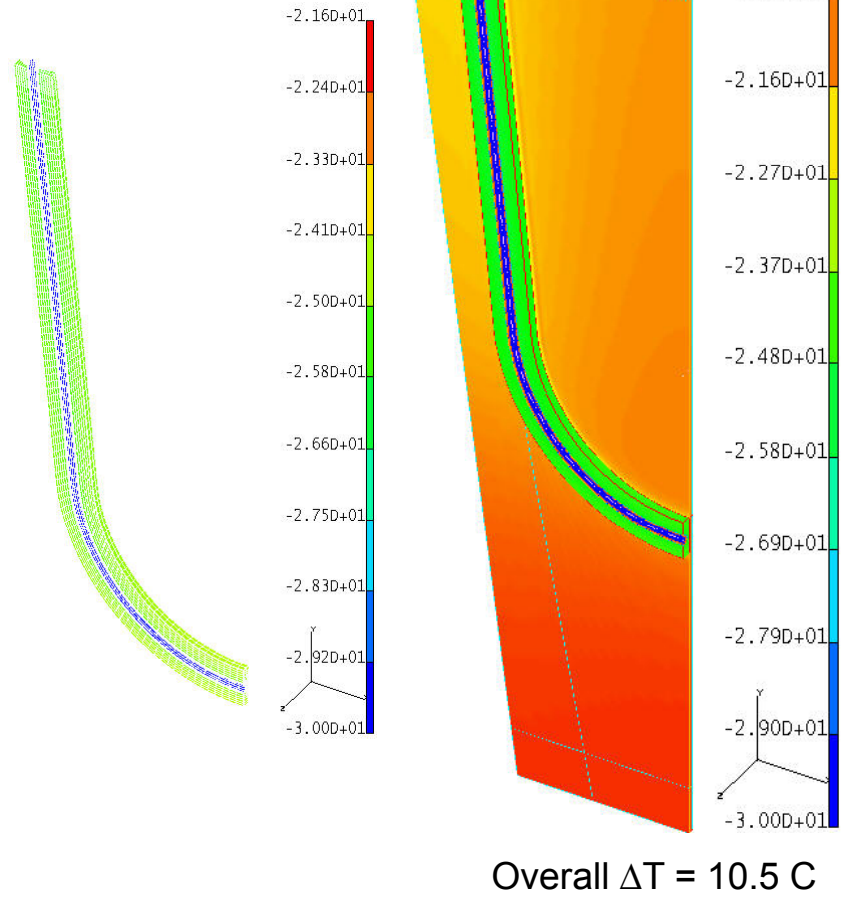
-30C on 0.88 mm ID tubing

Conf. A-T1: 0.06 cf + 0.50TPG + 0.06 cf Substrate

200% heat load (0.318 W/cm²)
4.44 W on this half substrate

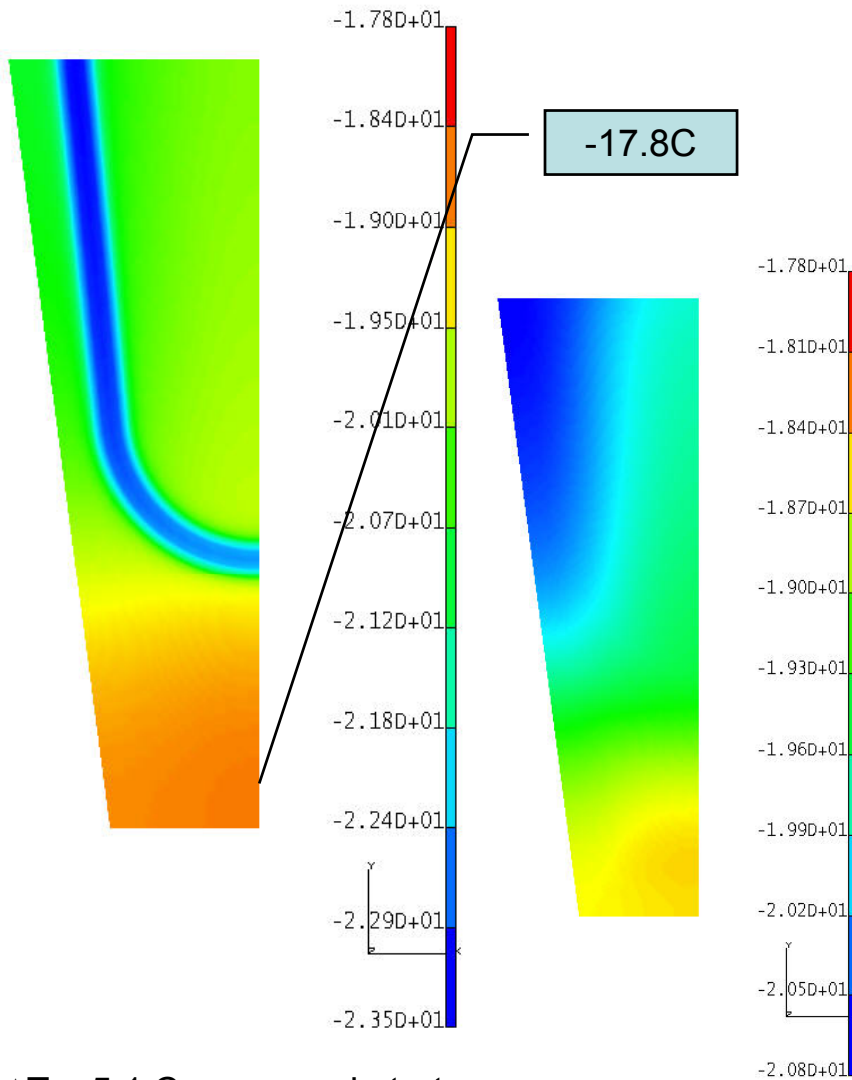


$\Delta T = 8.4\text{ C}$
from tube to epoxy

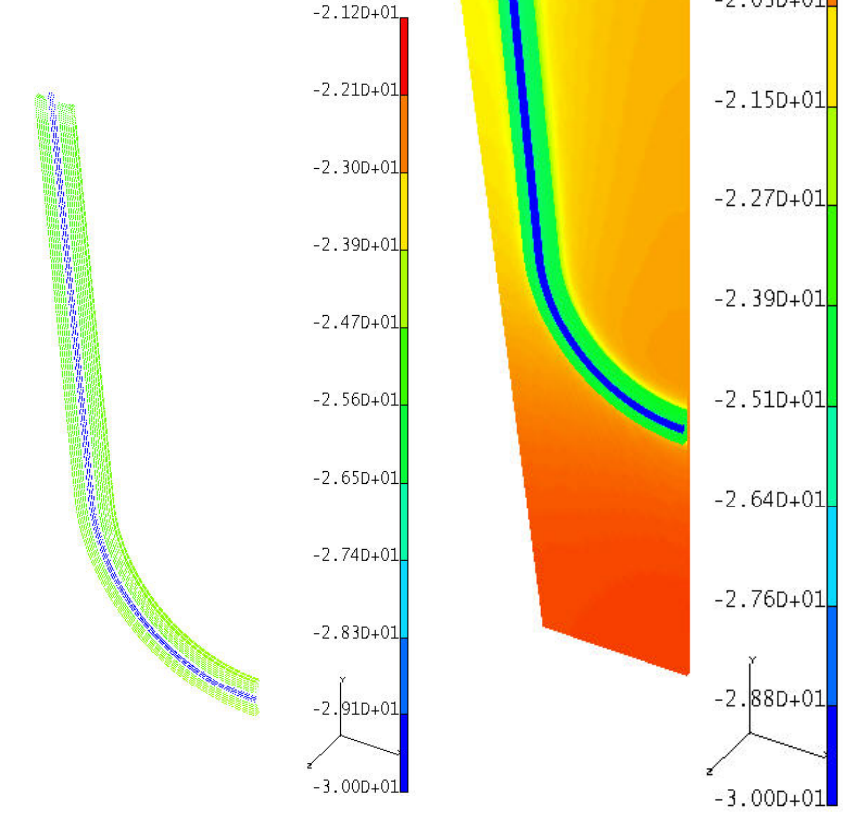


Conf. A-T2: 0.12 cf + 0.38TPG + 0.12 cf Substrate

200% heat load (0.318 W/cm²)
4.44 W on this half substrate



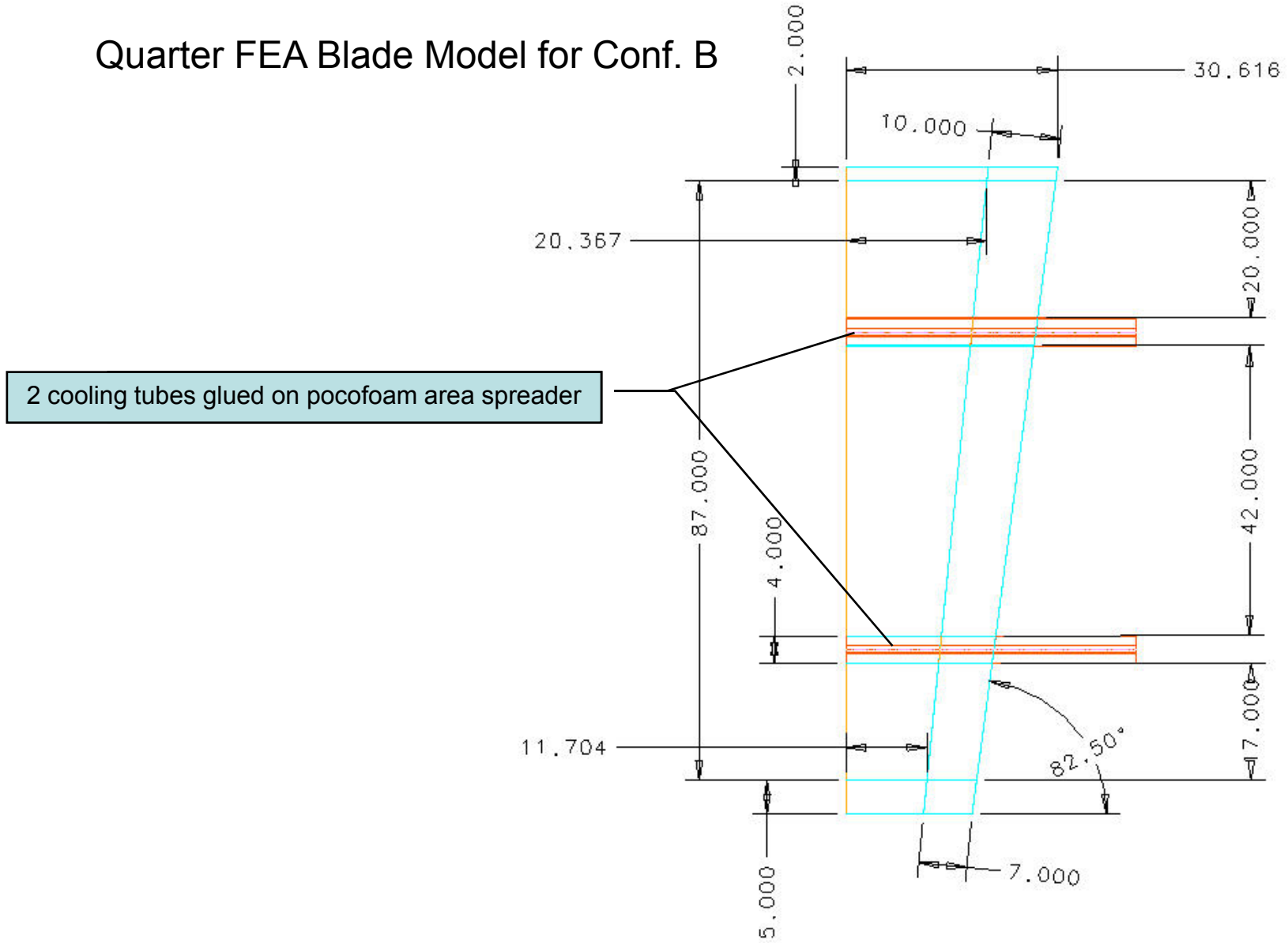
$\Delta T = 8.8 \text{ C}$
from tube to epoxy



$\Delta T = 5.1 \text{ C}$ across substrate
 $\Delta T = 3 \text{ C}$ across cf top facing

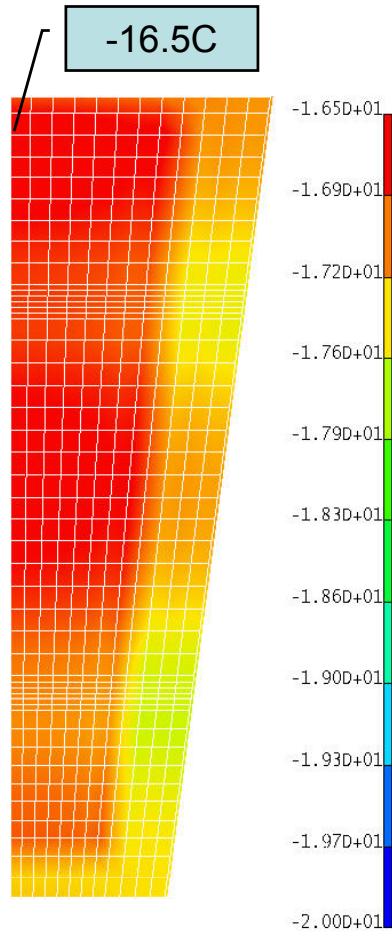
Overall $\Delta T = 12.2 \text{ C}$

Quarter FEA Blade Model for Conf. B

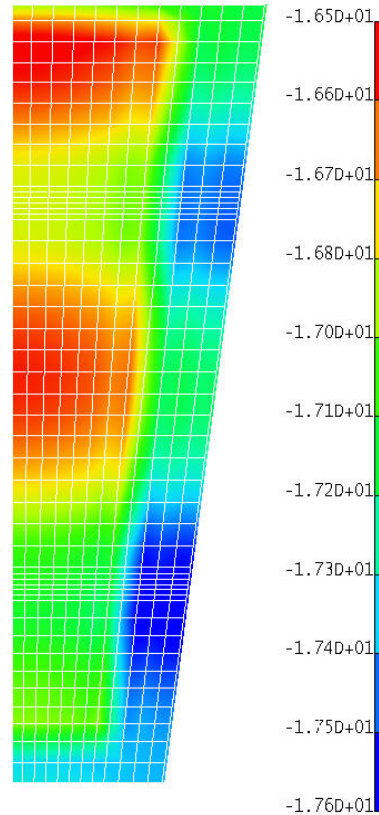


Conf. B-T1: 0.06 cf + 0.50TPG + 0.06 cf Substrate

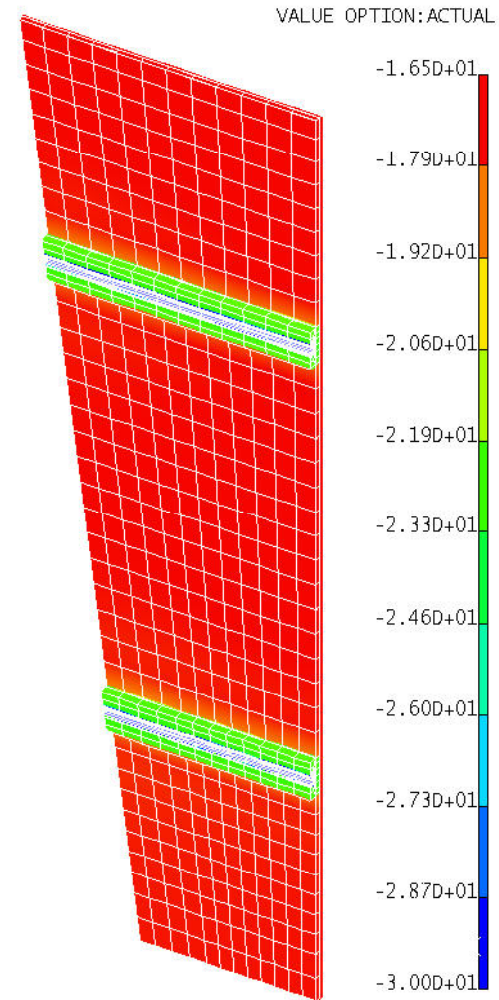
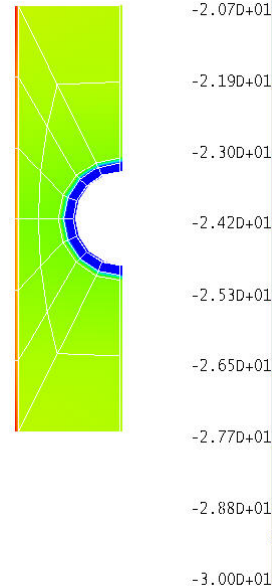
200% heat load (0.318 W/cm²)
4.44 W on this half substrate



$\Delta T = 3.5$ C across substrate
 $\Delta T = 1.1$ C across cf top facing



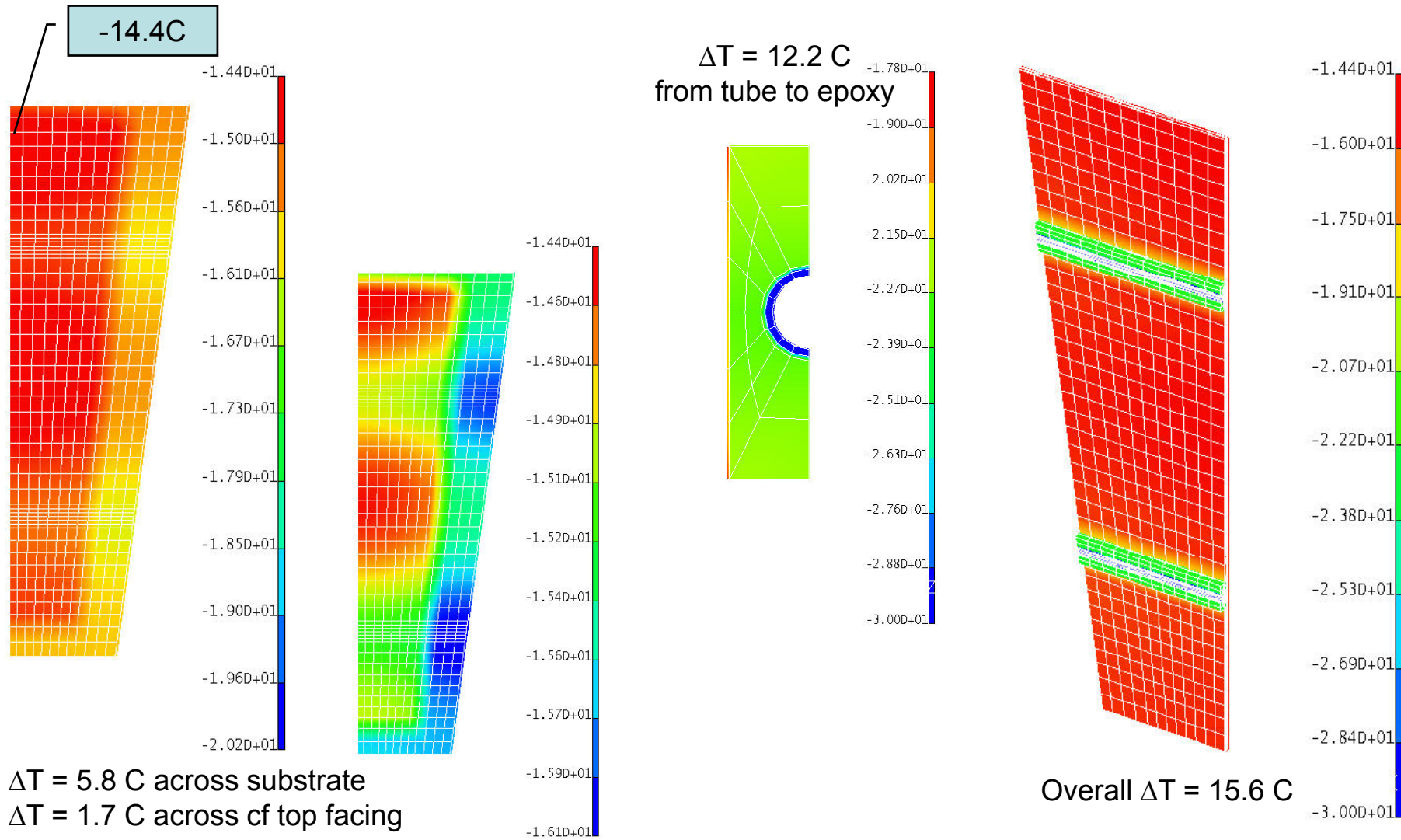
$\Delta T = 11.6$ C
from tube to epoxy



Overall $\Delta T = 13.5$ C

Conf. B-T2: 0.12 cf + 0.38TPG + 0.12 cf Substrate

200% heat load (0.318 W/cm²)
4.44 W on this half substrate



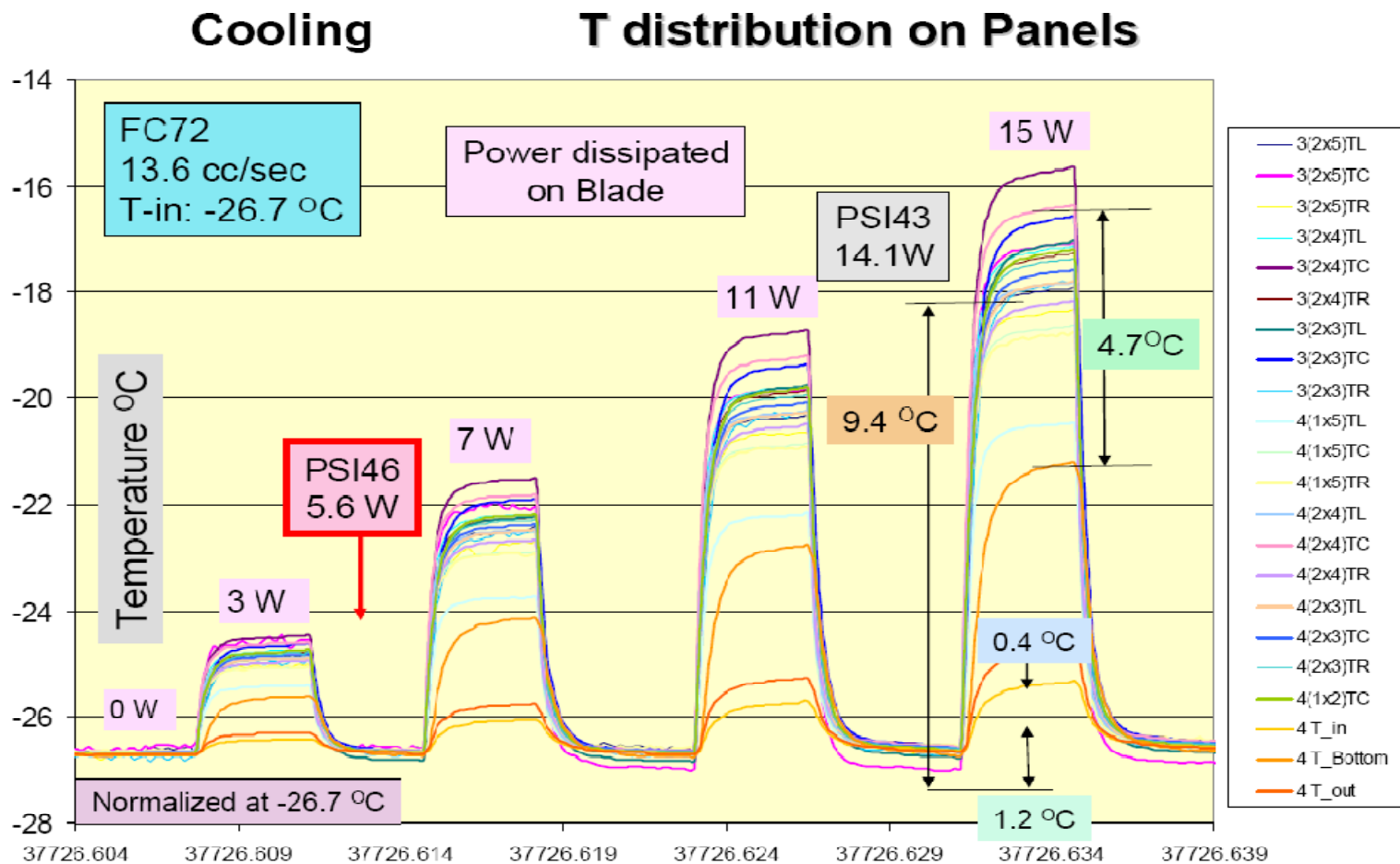
Summary of Results

<< All substrates are with overall thickness 0.62 mm and under 200% heat load >>

Configuration	ΔT , tubing	ΔT , tube epoxy	ΔT , foam	ΔT , subs epoxy	ΔT , substrate	ΔT , overall
A-T1	0.2	5.2	1.3	3.7	3.8	10.5
A-T2	0.2	5.2	1.3	4.2	5.1	12.2
B-T1	0.3	7	1	4.5	3.5	13.5
B-T2	0.3	7	1.1	5.1	5.8	15.6
A - beryllium					13.9	19.4

Configuration A-T1 performed the best with least temperature drop.

For Comparison



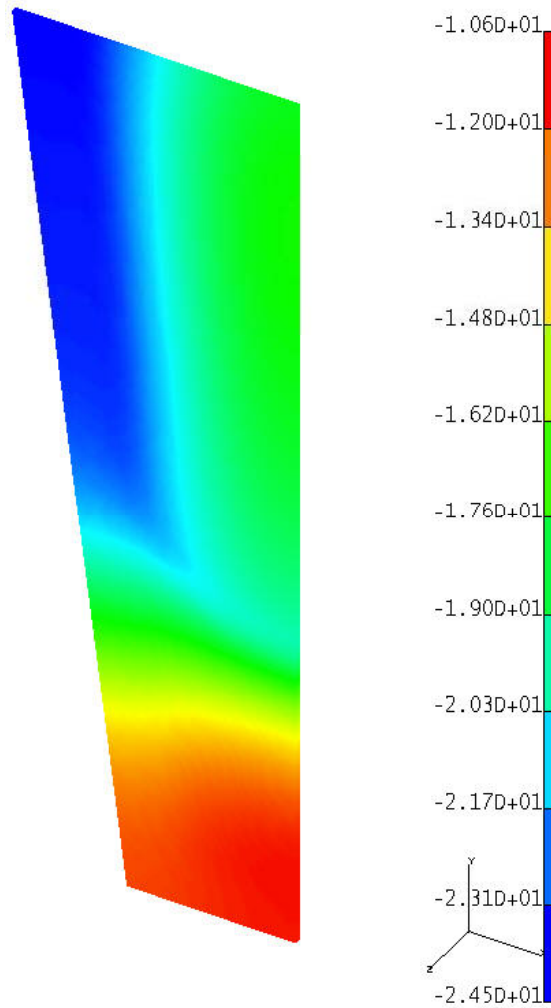
CERN, September 10, 2003

LHCC – Referee Meeting

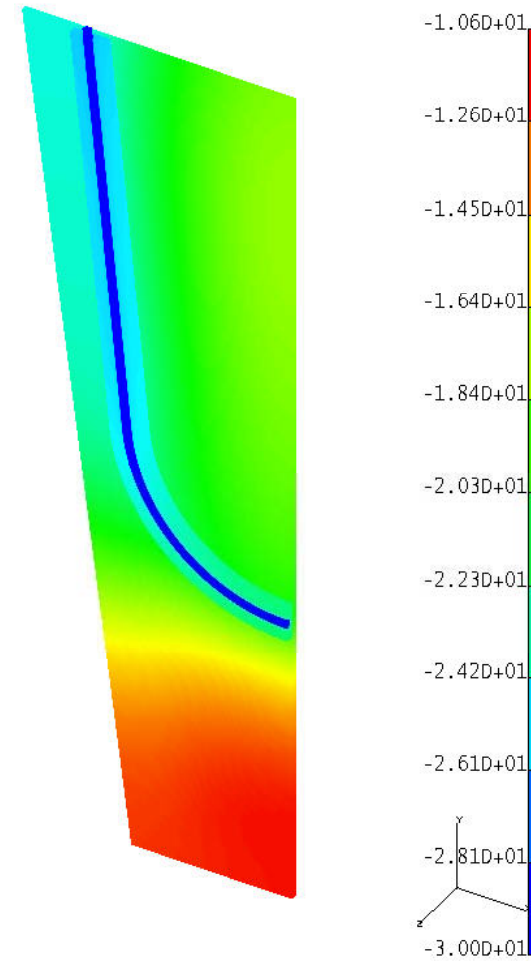
step apr 15-03.xls

Conf. A: 0.62 mm thick Beryllium Substrate

200% heat load (0.318 W/cm²)
4.44 W on this half substrate



$\Delta T = 13.9$ C across substrate



Overall $\Delta T = 19.4$ C

Conclusions on this FEA with 200% Heat Load

- The temperature drops across the substrate were small.
- The temperature drops across the tubing and pocof foam were small.
- The major temperature drops occurred across the epoxy layers.
- The temperature drops of the thicker TPG with 1-ply cf facings configuration (-T1) were slightly better than the thinner one (-T2) by about 2 degrees C.
- In some previous FEA work,
 - The direct gluing of the small tubing to the TPG would result in a huge temperature drop. (~15 C more). An area spreader made of pocof foam or CC might be preferred.
 - The thermal performances of the pocof foam and CC were found about the same.
- For the cooling layout of configuration A, the major temperature drops across the substrate should be even smaller if the tip of the U-shape cooling tube is pushed deeper towards the beam axis. (It may not be preferred as it means more mass of material in region closer to the beam.)

Proposed Conceptual Design

- TPG will be used for the core of the substrate.
- The major function of the carbon fiber facing is to provide the encapsulation. This can be simply made by adding one ply of carbon fiber reinforced plastics (CFRP). So 1 ply K139-EX1515 CFRP will be used unless extra rigidity is needed.
- Pocofoam is much less expensive than CC and much easier to make. Pocofoam will be tried first.
- The U-shape cooling line profile will be used. The tip of the U channel may be arranged 10~20 mm closer to the beam axis if acceptable.